Characterization of Carbon Films Prepared from Polybenzoxazine Films

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Two types of polybenzoxazine films, PBA and PPd, that were prepared by the thermal cure of benzoxazines, Ba and Pd, were carbonized at temperature-controlled condition, and the effect of the chemical structure of the polybenzoxazines on carbonization was examined by comparing with the carbonization behavior of polyimide film. X-ray diffraction and X-ray photoelectron spectra measurements showed that the carbon films prepared by heat treatment of rigid polybenzoxazine, PPd, at 900 °C and 1000 °C were the most graphitized. Micrographitic structure was confirmed by transmission electron microscope observation for the carbonized films of PBA and PPd at 1000 °C.

Keywords: polybenzoxazine, phenolic resin, carbonization

1. Introduction

Carbonization process of polymer strongly depends on the molecular structure and the higher ordered structure of the polymer. There have been various reports on the carbonization and graphitization of aromatic polymers such as polyoxadiazole (POD) [1, 2] and polyimide (PI) films. It was found that carbonization and graphitization of POD and PI with planar and rigid structure take place easily [3]. Especially, carbonization and graphitization of PI were extensively studied because of the molecular design flexibility of PI. The effects of chemical structure of PI [4], cold-drawing of PI film [5-7], and constraint during imidization of poly(amide acid) [8] on carbonization and graphitization have been extensively reported on the Kapton type PI, PI(PMDA/ODA) [9], and other PI films [10-14]. It was also revealed that carbonization of PI films give microporous carbon films by thermally treating PI films at 700-900 °C [15, 16]. Furthermore, it was reported that the thermal degradation of poly (urethane-imide) gave porous PI film [17-19] which further leads porous carbon film [20, 21].

On the contrary, it is known that the carbonization and graphitization of phenolic resin having complex three-dimensional structure are rather difficult [22, 23]. Recently, polybenzoxazines prepared by the ring-opening polymerization of cyclic monomers, benzoxazines, are recognized as a new type of phenolic resin [24]. It is known that polybenzoxazine has good flame retardance and high char yield, however, there is no study on the carbonization of polybenzoxazine.

In this study, carbonization of polybenzoxazine films prepared by two types of benzoxazines, Pd and Ba, was examined (Fig. 1). The carbonization was of these polybenzoxazine films was compared with that of a typical polyimide, PI (PMDA/ODA) (Fig. 2).

2. Experimental

2.1. Materials

Aniline, paraformaldehyde and 4,4’-oxydianiline (ODA) were purchased from Wako Pure Chemicals. Bisphenol A and pyromellitic dianhydride (PMDA) were purchased from Kishida Chemicals. Pd was kindly supplied by Shikoku Chemicals, and purified by washing with 2.0 mol/L of aqueous sodium hydroxide and water. Ba was synthesized from bisphenol A, aniline and paraformaldehyde by the conventional solvent-less method for 30 minutes at 120 °C.

2.2. Preparation of Polybenzoxazine Films

One gram of benzoxazine, Ba or Pd, was
dissolved into 3.0 ml of THF. The THF solution was cast on a silanized glass plate and heated at 60 °C for 16 h, and then at 100 °C, 160 °C, 200 °C, and 240 °C for 1 h each.

2.3. Preparation of PI Films

ODA and PMDA were reacted in N-methyl-2-pyrrolidinone (NMP) under nitrogen for 4 h at room temperature, giving viscous poly(amide acid) (PAA) solution, which was cast on a glass plate and heated at 50 °C for 16 h, and then at 100 °C, 200 °C, 300 °C, and 350 °C for 1 h each, affording yellow PI film with thickness around 50 μm.

2.4. Preparation of Carbon Films

Polymer film was cut into 50 mm × 50 mm and sandwiched between porous alumina plates, and then heated at 800 °C, 900 °C, and 1000 °C for 1 h each under nitrogen atmosphere at a heating rate of 10 °C/min.

2.5. Measurements

1H NMR spectra were recorded on a JEOL JNM-EC400 (400 MHz) at room temperature. Fourier transform-infrared (FT-IR) spectra were recorded on a JASCO FT-IR420 spectrometer equipped with an ATR 450-s unit. Differential scanning calorimetry (DSC) was measured on a Rigaku DSC8230 at a heating rate of 10 °C/min under nitrogen atmosphere. Thermogravimetric analyses (TGA) were measured on a Rigaku TG8120 at a heating rate of 5 °C/min under argon atmosphere. X-ray diffraction patterns (XRD) were recorded on a Rigaku RINT2000 and RINT2200 using Cu-Kα radiation. X-ray photoelectron spectra (XPS) were measured by a ULVAC-PHI Quantera SXM-CL. Transmission electron microscope (TEM) observations were conducted on a JEOL JEM-2100F. Nitrogen adsorption isotherms were measured by an automatic adsorption apparatus (Quantachrome AUTOSORB-1) at -196 °C.

3. Results and Discussion

3.1. Carbonization of Polybenzoxazine and Polyimide Films

Carbonization of PI, PBa, and PPd films gave carbon films with silver metallic luster, which suggests that all the carbon films were graphitized to some degree.

Carbon yield and dimensions of carbon films are shown as Table 1. Yields of carbon films were in the
order of PI > PPd > PBa, which corresponds to the
char yield determined by TGA measurements of
polymer films (Table 2). Aromatic content was
calculated to be 66% for PPd, 62% for PBa, and
52% for PI, which corresponds to the different
thermal decomposition behavior between
polybenzoxazines and polyimides.

It was also observed that PI film did not shrink so
much during carbonization in the direction of
thickness as compared with PBa and PPd. This was
considered to be due to the high in-plane orientation
of PI film.

### Table 1. Dimensions and carbon yields of carbon films.

<table>
<thead>
<tr>
<th>Polymer</th>
<th>Length (%)</th>
<th>Thickness (%)</th>
<th>Yield (%)</th>
</tr>
</thead>
<tbody>
<tr>
<td>800 °C</td>
<td>77</td>
<td>94</td>
<td>57</td>
</tr>
<tr>
<td>PI</td>
<td>900 °C</td>
<td>76</td>
<td>94</td>
</tr>
<tr>
<td>1000 °C</td>
<td>76</td>
<td>93</td>
<td>47</td>
</tr>
<tr>
<td>800 °C</td>
<td>74</td>
<td>65</td>
<td>34</td>
</tr>
<tr>
<td>PBa</td>
<td>900 °C</td>
<td>72</td>
<td>60</td>
</tr>
<tr>
<td>1000 °C</td>
<td>71</td>
<td>57</td>
<td>26</td>
</tr>
<tr>
<td>800 °C</td>
<td>75</td>
<td>74</td>
<td>48</td>
</tr>
<tr>
<td>PPd</td>
<td>900 °C</td>
<td>74</td>
<td>73</td>
</tr>
<tr>
<td>1000 °C</td>
<td>74</td>
<td>70</td>
<td>41</td>
</tr>
</tbody>
</table>

### Table 2. Char yields of polymer films on TGA
measurements at a heating rate of 5 °C/min under argon
atmosphere.

<table>
<thead>
<tr>
<th>Polymer</th>
<th>Char yield (%)</th>
</tr>
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<tbody>
<tr>
<td>800 °C</td>
<td>52 45 37</td>
</tr>
<tr>
<td>900 °C</td>
<td>24 24 15</td>
</tr>
<tr>
<td>1000 °C</td>
<td>47 38 30</td>
</tr>
</tbody>
</table>

3.2. XRD of Carbon Films

XRD patterns of carbon films are shown in Fig. 3.
XRD of the carbon films showed peaks attributable
to (002) and (101) at 2θ = 25° (d = 0.35 nm) and 44°
(d = 0.29 nm), respectively. The diffraction peaks of
the (002) plane was observed in the diffraction
patterns of all carbon films, but the peak was broad,
suggesting that all carbon films include the
turbostratic structures and/or micrographite
structure.

Figure 4 shows the change of the intensity of the
diffraction peak of the (002) plane of each carbon film prepared at different carbonization temperature. The intensity of the (002) plane increased with increasing the carbonization temperature for all the carbon films. Therefore, graphitization would develop with increasing carbonization temperature. Among the carbon films examined, the diffraction intensity of the (002) plane of carbon film of PPd was the highest. This suggests that development of graphitization is most pronounced for PPd that have a rigid structure.

3.3. XPS of Carbon Films

XPS measurements of the carbon films were conducted on the surface and also on the inner part being etched for 0.5 nm from the surface to estimate the graphitization ratio of the carbon films. XPS of carbon films are shown in Fig. 5. Observed peaks of carbon was accurately fitted by four waveforms, sp² hybrid orbital (284.3 eV), sp³ hybrid orbital (285 eV), sp² satellite peak (287 eV), and 1S orbital of C-O (289 eV). It is considered that sp² satellite peak is based on $\pi-\pi^*$ electron transition.

Graphitization ratios of the carbon films were estimated by the ratio of sp² hybrid orbital among all the peaks except 1S orbital of C-O and sp² satellite peak, and summarized in Table 3. Graphitization ratios on the surface and the etched part of PPd were higher than those of PBa and PI. There results suggest that graphitization of PPd is even more significant than PI, which is known as easily graphitizable polymer, and considered to be very interesting.

Fig. 5. XPS of carbon films. Surface: a) PI, b) PBa, c) PPd, etched part: a’) PI, b’) PBa, c’) PPd.
3.4. TEM Observation of Carbon Films

TEM images of the carbon films prepared by the thermal treatment of PBa, PPd and PI at 1000 °C are shown in Fig. 6. Lattice fringe images of micrographitic structure were observed in the carbon films, indicating that the polymers easily graphitized at 1000 °C.

3.5. Nitrogen Adsorption Measurements of Carbon Films

The nitrogen adsorption isotherms of the carbon films of PPd were measured, to characterize porous features of the materials. It has already reported that PI gave microporous carbon films by the thermal decomposition [15, 16]. However, as shown Fig. 7, no microporous structure was detected in the carbon films from PPd by the adsorption of N2. The macroporous stuctures decreased with increasing the carbonization temperature for the carbon film of PPd.

4. Conclusion

Judging from XRD and XPS measurements, the carbon films prepared by the heat treatment of PPd having a rigid structure at 900 °C and 1000 °C were the most graphitized. It is very interesting that PPd is easier to graphitize than PI which is known to be an excellent graphite precursor.

References